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Automated Handling and Assembly of Customizable AFM-Tips

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Abstract—Today’s processes in micro- and nanofabrication include several critical dimension metrology steps to guarantee device performance. Especially in the manufacturing process of novel disruptive photonic devices and nanoelectronic circuit architectures, new 3D acquisition and visualization techniques for metrology are required. Two of the most important parameters are the line width and sidewall roughness of vertical interconnects and nano-optical structures. The measurement of these parameters becomes increasingly challenging as the continuous shrinking of dimensions requires higher lateral resolution. The AFM has become a standard and widely spread instrument for characterizing such nanoscale devices and can be found in most of today’s research and development areas. However, the characterization of three dimensional high-aspect ratio and sidewall structures is still a bottleneck. Novel exchangeable and customizable scanning probe tips, so-called NanoBits, can be attached to standard AFM cantilevers offering unprecedented freedom in adapting the shape and size of the tips to the surface topology of the specific application. In order to realize the in-situ exchange of NanoBits within the AFM environment the NanoBits have to be provided in a freestanding way that allows the AFM cantilever to be aligned and connected to the NanoBits. Due to the fact that direct microfabrication of such structures is still challenging, a nanorobotic preassembly of NanoBits cartridges is reasonable. These cartridges are intended to contain several NanoBits with a variety of different tip-shapes.

Keywords—nano-assembling; automation; AFM-tip; customizable; characterization; optical waveguide

I. INTRODUCTION

Industries in micro- and nanotechnology produce devices, which are supposed to have well-defined properties in order to guarantee their performance. To achieve and keep these properties, various metrology steps for process control are required and especially measurements at the critical dimension – meaning where the system reaches its resolution limit – gain importance. In recent years, the production and development of integrated optical devices with optical waveguides and complex photonic systems have become one of the most crucial tasks in micro- and nanosystems technology.

For these components, not only surface roughness measurements on horizontal flat zones, but also measurements on vertical surfaces and on the width of groves are important. On account of the miniaturization, all these tasks will become even more challenging.

The Atomic Force Microscope (AFM) has become a standard and widely spread instrument in industry and research for the characterization of nanoscale devices. However, the capabilities of the AFM are still limited by the geometry of AFM-tips which only allows the analysis of horizontal surfaces with low aspect-ratios. A variety of research projects tackle these problems, aiming for an general improvement of AFM-cantilevers. Several works have shown, that refinement or decoration of AFM-tips can improve the imaging quality – especially all the aspect-ratio – by orders of magnitudes [1]–[3].

To date, roughness measurements on vertical or even over-hanging surfaces are hardly feasible. The most apparent reason is that it is impossible to bring the cantilever tip into contact with these points within the given geometrical conditions. Furthermore, controlling methods for scanning movements in planes with arbitrary orientation are still lacking.

This contribution deals with the development of novel, exchangeable, and customizable AFM-tips. These tips – called NanoBits – can be mounted at the tip of a conventional AFM-cantilever or at the end of a conventional tipless AFM-cantilever. Thus, they are optionally designed to be integrated within a commercial AFM system. NanoBits offer entirely new possibilities to design the shape and size of scanning tips. Almost any orientation of the tip is possible and even multi-tip NanoBits are possible. Thus, NanoBits prove a more detailed characterization of complex structures than has been achieved to date [4].

A fundamental goal of this contribution is the development of an automated in-situ exchange of NanoBits, since this guarantees seamless integration into conventional AFM systems and processes. However, the assembly of a NanoBit with an AFM-cantilever imposes certain conditions on the setup:

- The NanoBits have to be freestanding, accessible, and perpendicular to the carrying substrate.
- The NanoBits have to be in a well-known position to enable the alignment and assembly of NanoBit and Cantilever.

The direct microfabrication of such freestanding structures is still challenging while a nanorobotic preassembly approach is very promising for the industrial exploitation. Several NanoBits can be stored in a cartridge to make them accessible.
Fig. 1: SEM image of a NanoBit substrate. Each NanoBit is suspended to the silicon beam at a single point and free pending above the substrate’s surface.

for the subsequent assembly. Every cartridge can contain different NanoBits for different applications and scanning tasks.

The transfer of the NanoBits from the production substrate to the cartridge is performed by special structured microgrippers. For this kind of application, handling approaches based on microgrippers allow a high throughput. In combination with a cost-effective microrobotic system that might be provided together with the AFM or NanoBits, such cartridges can be integrated into the AFM environment enabling an easy and in-situ exchange of NanoBits AFM probes. The entire sequence of a NanoBit’s production and application contains four main stages:

i) The lithographic fabrication of the NanoBits.

ii) The transfer from the fabrication substrate to a cartridge.

iii) The transfer from the cartridge to the tip of a cantilever.

iv) The removal of the NanoBit from the cantilever’s tip.

Due to deformations at all scanning probe tips, multiple usage of a single NanoBit is neither necessary nor intended.

Section II of this contribution gives a short introduction to the NanoBits and their fabrication possibilities. Section III explains the fundamental handling strategies in detail as well as experimental results and the closing Section IV gives a short overview of the used and intended automation techniques.

II. NanoBits: Customizable AFM-Tips

The tip morphology of the NanoBits can be accurately shaped to match the individual application. In order to conduct AFM scanning in special modes (sidewall roughness, overhanging edges, high aspect ratio) a particular shape of the tip is typically required. In previous work, NanoBits have been prepared by electron beam lithography (EBL) and standard silicon processing. In this way, NanoBits could be produced suspended on a tiny contact and free lying above the substrate (Fig. 1). The dimensions are 2-5 μm long and 120-150 nm thick, while the length of the handle is user-definable.

A. Precise fabrication of NanoBits by FIB

In this work, a second approach, focused ion beam (FIB) milling is used for rapid fabrication of custom-made prototype AFM tips with a very short turn-around time. The enduser can then easily prepare his own tip with an application-specific shape in less than half an hour, without access to a cleanroom. A focused gallium ion beam at a Helios NanoLab micromachining system is used to manufacture NanoBits in a 130 nm thin silicon membrane. The focus of this study is to obtain a precisely manufactured geometry despite well-known focused ion beam milling issues like drift and redeposition. Finally, the fabrication tolerance can approach to tens of nanometers.

The resulting shape of the structure depends significantly on the sequence in which the different parts of the pattern are milled, i.e. the milling strategy. The most simple raster scanning turned out to be highly sensitive to drift and redeposition of sputtered material, which results in severe shape distortion. The drift can be caused by thermal instability of the system, residual movement of the stage, charging effects of the sample and other factors. The resolution of high end FIB milling approaches a level where residual electro-magnetic interference is difficult to compensate by regular measures such as interference interlock of power supply and antiphase suppressing coils installed in the laboratory. Usually a small drift of the milled pattern relative to the sample occurs due to several reasons. The sample stage may continue to drift immediately after a previous movement has been performed, but this effect usually quickly diminishes. Temperature drift of the equipment construction and electronics is a more persistent problem. Furthermore, placing the sample on sticky carbon tape or other mechanically unstable supporters may cause creep or drift. For some types of samples electrical charging can be a problem as well. While such effects can be reduced to some extent, the small residual drift is typically unpredictable as it depends on many factors.

Different patterning strategies are used in the endeavor of minimizing shape distortions. The main points are the following: the milling order is automatically organized to mill the critical areas last, which reduces problems with redeposition. This is done by defining a multiple circular milling pattern with a center in each critical area of the structure, as shown in Figure 4a. Moreover, an automatic back scan of the already

Fig. 2: SEM views of NanoBits prepared by FIB etching in the Si membrane.
milled contour removes redeposited material. A serial snake-like mill order of the edge is used to eliminate artifacts induced by the movement of the beam; occasionally traces are etched on the surface because of incomplete blanking (suppression) of the ion beam. The best and most robust, design-independent strategy turned out to be a combination of the above-mentioned strategy elements (see Figure 4b). This results in a significantly more uniform and geometrically exact shape of the structure. In addition to the drift of the pattern, a minor drift of the focus was observed. To counteract this, the objective lens voltage must be manually corrected by roughly 20 V per hour to maintain a correct focus, with the maximum value being about 19 kV. This corresponds to a 20 nm defocusing of the beam spot at 28 pA beam current.

Sharpening the NanoBit tips for high resolution scanning probe microscopy using a focused ion beam is a challenging problem. Tip diameters of 30-40 nm are easily obtained by FIB, but 10 nm or less is typically required for AFM measurements. TEM imaging helps to evaluate the acquired shape and dimensions of the NanoBits, observe changes in the crystal structure as well as possible formation of amorphous layer from redeposition during the milling process, and also to understand underlying tip formation mechanisms [7]. Figure 5a shows an example in which the sharpening of the tip has led to structural damage, possibly due to overheating or excessive amorphisation. The smallest tip diameter obtained by simple FIB milling from the side is approximately 23 nm (Fig. 5b). In the following experiment an accelerating voltage of 30 kV was used, and an ion beam current of 28 pA. For better sharpening, it is preferable to etch along a tangent from the base towards the end of the needle shaped tip. Other sharpening strategies will also be investigated.

III. ASSEMBLY AND INTEGRATION OF NANOBITS AFM PROBES

The preassembly sequence makes high demands on the setup, since it has to be assured that the NanoBits tips remain undamaged during the entire process. Thus, high positioning accuracy in nanometer range is required for the manipulation. High resolution visual feedback serves as monitoring for the handling process as well as quality control unit. In order to fulfill all these requirements, it is reasonable to mount the robotic setup inside a scanning electron microscope (SEM). It provides sufficient room for all components and a high-capacity imaging system with the accuracy of few nanometers [9].

The presented setup is integrated in a Tescan Lyra FEG high resolution microscope with an additional focused ion beam unit (FIB). On the one hand, the FIB is used to structure the gripper-jaws, on the other hand, it provides an imaging system with an additional point of view to the SEM’s perspective which allows the collection of much more information about the system’s pose.

A. Robotic System

The experimental setup mounted inside the SEM is developed with the objective of being versatile for different nanomanipulation and -handling tasks. Thus, the setup is modularly designed and consists of a coarse- and a finepositioning unit [10]. Each unit possesses three linear degrees of freedom while the coarsepositioning unit offers a maximal stroke of 35 mm in x/y-direction and 27 mm in z-direction, the finepositioning unit offers a maximal stroke of 50 μm in all directions. The actuators are equipped with internal optical sensors enabling a closed-loop accuracy of at least 500 nm and internal optical sensors enabling a closed-loop accuracy of at least 1.6 nm, respectively.

According to the automation of the preassembly, the combination of coarse- and fine positioning units provides crucial benefits. High strokes allow mounting several reachable samples in the same setup, which is important for a fully automated preassembly process without any manual modification of the setup. On the other hand, high accuracy allows
Fig. 6: Scheme of the NanoBit’s detaching: a) The NanoBit is parallel to the substrate’s surface. b) The NanoBit performs an out-of-plane turn and detaches from the substrate. c) The NanoBit is places in a cavity of the cartridge.

performing well-controlled movements in order to guarantee damage-free handling of the NanoBits.

B. Handling Strategies

During its application a NanoBit has to be transferred at least three times:

i) During the preassembly - from the fabrication substrate to the cartridge.

ii) During the application in the AFM - from the cartridge to the tip of the cantilever.

iii) At the disposal - cantilever has to be freed of the used NanoBit facilitating mounting of a new NanoBit there.

As mentioned above, simple pick-and-place transfer is not feasible in the nanometer scale and each transfer step reveals additional particular problems. Hence, all transfer techniques and tools have to be designed according to the actual task but still adjusted dependent on all other requirements given by the different steps.

1) NanoBit Gripping: The first handling step after the fabrication is detaching the NanoBit from the fabrication substrate. It can be performed straightforward by the gripper, since the NanoBit’s suspension serves as predetermined breaking point, which allows detaching by the application of very small forces.

As the second step, the tip of the NanoBit is inserted into a cavity of the cartridge, which requires that the NanoBit’s tip be perpendicular to the substrate’s surface. The consequential 90° turn of the NanoBit can not be achieved by turning the entire gripper, since the gripper’s geometry would not allow the approach to the fabrication substrate. Thus, an out-of-plane turn inside the gripping plane is desired, which can be achieved by special structured gripping jaws for example. This strategy facilitates a fast and seamless gripping process (see Figure 6).

Generally, if standard grippers with parallel gripping-planes clamp a NanoBit, it will turn in the jaws at some time of the handling process, either clockwise or counter-clockwise. In order to benefit from this spontaneous effect, tilted gripping jaws can be used to give the NanoBit the preferred turning direction. Two different approaches are used which are based on a configuration, in which the NanoBit’s plane and the gripper’s jaw plane are already slightly tilted (see Figure 7):

i) The gripper is parallel to the substrate’s surface and only the gripping surfaces are tilted by about 5°. This configuration can not be directly achieved in the manufacturing process of the gripper which makes an additional structuring of the gripper necessary. A rotational momentum at the NanoBit occurs caused by the non-symmetric clamping. The advantage is a non-tilted configuration of the entire gripper and substrate preserving an environment without any constraints.

ii) The entire gripper unit is mounted tilted, while the angle is limited by the geometry constraints. Compared to the first approach, the advantage in this setup is, that the actuation direction of the gripper jaws is tilted as well. Thus, the NanoBits turning becomes even more probable, since the actuation treats the NanoBit with an actual rotational momentum.

For both approaches, the rotational momentum caused by closing the gripper jaws is more than sufficient to turn the NanoBit completely and detach it from the fabrication substrate at the predetermined breaking point.

Regardless of the approach, a FIB treatment of the gripping jaws is beneficial to the assembly process and especially the automation. Even if the gripping planes are not tilted, tapering the gripping tips is very useful. It allows a much better estimation of the grippers position in the on-top-view during the entire preassembly process and consequently facilitates better z-positioning and reliable automation. Figures 8 and 9 show SEM images of a FIB-structured thermoelectrical gripper. The inside of the gripper jaws are tilted and the tips are tapered.

Figure 9 shows the handling sequence of the preassembly process. Firstly, gripper and NanoBit have to be aligned, a further closing of the gripper-jaws causes the NanoBit to turn
to the point of a full 90° detaching the NanoBit from the substrate. The closed gripper holds the NanoBit preventing an unintended bouncing during the break off. This strategy is performed with FIB-structured grippers as well as tilt-mounted grippers. Both approaches work quite well, while the tilted setup reveals more reliable results concerning the determination of the turning direction.

2) Preassembly: Placing the NanoBit in the cartridge is the most crucial step of the preassembly sequence, since it has to be performed allowing for parasitic forces in the nanometer scale – most of all adhesion and van der Waals linkage. Due to the tiny mass of the NanoBits, the gripper can open its jaws without obtaining a disengagement by gravity of gripper and NanoBit. For this reason, the cartridge already has to be designed in a way, that it can assist the gripper with placing and disengaging the NanoBit by overbearing the parasitic forces. On the other hand, it is of vital importance that the tip of the NanoBit remains undamaged until it is used. For this reason, the NanoBit’s tip is not allowed to touch any part of the cartridge during the preassembly process as well as the storage or transportation time. Therefore, the most adequate type of cavity is a narrow trench in a thin membrane. The dimensions of these trenches are about 200-300 nm in width and few μm in length, which guarantees that the tip of the NanoBit is already outside of the membrane and completely free ensuring contactless storage condition.

Figure 10 shows the placing strategy of NanoBit and cartridge. Firstly, the NanoBit has to be aligned above the cavity. The NanoBit is lowered subsequently until the NanoBit’s body and handle rest on the cartridge. Secondly, the gripper is opened and withdrawn. Since the NanoBit rests in the cavity, it will be detracted from the gripper jaws and stay in the cartridge.

The experimental realization of this sequence is shown in Figure 11. After the clamped NanoBit is inserted into the cavity (Fig. 11a), the opened gripper can be retracted parallel to the cartridge’s surface (Fig. 11b). The left NanoBit rests in the cavity, it is freestanding and accessible in the cavity (Fig. 11c).

3) Tip Exchange in the AFM: In order to address a wide application field, the in-situ exchange of NanoBits is highly aspired. This does not only concern the assembly of NanoBit and cantilever but also the release of the used NanoBit clearing the cantilever. The in-situ exchange demands several requirements:

i) All assembly steps must not involve complex joining-technologies.

ii) All assembly steps have to be reliable, damage free and verifiable. Especially, the NanoBit’s release has to clear the Cantilever without any remainders.

iii) The AFM in-situ exchange declares the SEM usage impossible. All assembly steps have to be feasible with light-optical or without optical feedback.

In any event, the assembly of NanoBit and cartridge is realized without any adhesive or additional force. Hence, the transfer to the cantilever needs a little bonding force only and can be realized by mechanical pinching. The entire sequence of the in-situ exchange is shown in Figure 12. The cantilever features a small conical trench at its end, which is pressed against the NanoBit from the top (Fig. 12a). During all the application steps, the NanoBit remains in the trench due to the mechanical pressure. After using, the cantilever, it can be freed from the NanoBit utilizing additional cavities with deep conical trenches. The cantilever can strip itself of the NanoBit in these trenches, because they offer a much higher contact surface to the NanoBit than the cantilever’s trench (Fig. 12c). Thus, reliable stripping can be realized.
The gripper is positioned exactly over the cavity. Then, when the NanoBit is located exactly between the gripper jaws [12].

IV. AUTOMATION OF NANOBits ASSEMBLY

To make the NanoBit's preassembly viable for industrial application, as described above, the process needs to be fully automated. Furthermore, the automation aims for a throughput of at least 6 components per minute. There are two main process steps involved in this automation: a) Detaching a NanoBit from the production substrate and b) putting a NanoBit into a target cavity. Keeping these steps in mind, the crucial challenges are the alignment of the NanoBit and gripper, and the NanoBit and cavity, respectively. These challenges need to be solved through the automation.

A. X/Y-Alignment

Firstly, objects need to be aligned in the x- and y-plane. In the gripper, the NanoBit and cavity is necessary, for the cartridge placing sequence even 50 nm are hardly sufficient in order to guarantee a damage-free assembly. In the handling setup, the precise location of the employed gripper, the NanoBits and the target cavities can only be determined using the SEM’s visual feedback. The robots’ internal sensors cannot guarantee movement with sufficient precision, due to temperature drift caused by the thermal gripper as well as electrostatic charging of the NanoBits. Thus, visual servoing is used for closed-loop positioning. In order to fulfill the throughput requirements, line scan-based tracking [11] is used to facilitate high-speed positioning. With this approach, the gripper can be aligned precisely with respect to a NanoBit in a few tens of milliseconds.

B. Z-Alignment

Secondly, a precise z alignment needs to be performed, which is much more complex due to the total lack of depth information from the SEM. Thus, two different approaches are used, dependent on the process step.

1) Alignment of gripper and NanoBit: To detach a NanoBit, the gripper is first aligned in the x/y-plane so that it is above the NanoBit and the NanoBit is visible between the gripper jaws. Then, the gripper is lowered until significant shadowing appears on the NanoBit. This shadow-based depth detection capitalizes on the fact that most secondary electrons hit the gripper and do not reach the electron detector when the NanoBit is located exactly between the gripper jaws [12].

2) Alignment of NanoBit and cavity: To release the NanoBit into a cavity, the tip of the NanoBit within the closed gripper is positioned exactly over the cavity. Then, when the gripper is lowered, the handle of the NanoBit will come into contact with the edge of the cavity leading to slight bending. This bending can be rapidly detected by the line scan-based tracking and the NanoBit can be released.

V. CONCLUSION

The robotic preassembly is a reliable approach to achieve the realization of an AFM system using exchangeable scanning tips. Several crucial steps are identified and corresponding handling sequences proposed. The handling of NanoBits using structured or tilted grippers, and the placement of NanoBits in cavities are revealed to be promising techniques for the realization of NanoBit cartridges. The experiments have shown, that further automation is definitely feasible, due to well known experimental conditions and parameters of all objects.

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